| Application No. | Applicant(s) | |
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| 10/811.808 | CHAE ET AL. | |
| Examiner | Art Unit | |
| Wai-Sing Louie | 2814 | |
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| f this communication to file NT of this application. | a reply complying with the requirements | |
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| be submitted. | | |
| n's Patent Drawing Review | (PTO-948) attached | |
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| 6. ☐ Interview St Paper No./), 7. ☐ Examiner's | ummary (PTO-413), Mail Date Amendment/Comment | |
| | Examiner Wai-Sing Louie rs on the cover sheet with DR REMAINS) CLOSED in rother appropriate community. This application is send MPEP 1308. er 35 U.S.C. § 119(a)-(d) concentration and MPEP 1308. | Examiner Wai-Sing Louie Provided For Act Unit Wai-Sing Louie Provided For Act Unit Wai-Sing Louie REMAINS) CLOSED in this application. If not included rother appropriate communication will be mailed in due course. THE HTS. This application is subject to withdrawal from issue at the inition MPEP 1308. Been received. Been received in Application No Been received in Application from the finite state of the submitted of the submitted. Been received in Application is deficient. Been submitted. Been received in this national stage application from the submitted. Been received in this national stage application from the front of this application. Been received in this national stage application from the finite stage application in the front of this application from the finite stage application from t |

Allowable Subject Matter

The following is an examiner's statement of reasons for allowance:

The prior art of record does not disclose or suggest either in singularly or in combination the following limitations and other elements in the claims. Reference Hata et al. (US 6,649,942), Hiraoka (US Pub. 2001/0002139), and Shakuda et al. (US 6,107,648) do not disclose:

An alloy layer which is formed on the upper clad layer to directly contact a
 surface of the upper clad layer, consists essentially of Zn and Ni, and absorbs
 hydrogen existing on the surface of said upper clad layer to prevent the p-type
 dopant from combining with said hydrogen.

Therefore, the above references do not disclose the claimed invention of present application and claims 1-2, 5, and 15-17 are allowed.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Wai-Sing Louie whose telephone number is (571) 272-1709. The examiner can normally be reached on 7:30 AM to 4:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on (571) 272-1705. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Wai-Sing Louie Patent Examiner

Wsl July 19, 2006.